

Inventor Name Search Result

Your Search was:

Last Name = ISHIBASHI

First Name = KEIJI

Application#	Patent#	Status	Date Filed	Title	Inventor Name 27
10673238	Not Issued	030	09/30/2003	HEATING ELEMENT CVD SYSTEM AND CONNECTION STRUCTURE BETWEEN HEATING ELEMENT AND ELECTRIC POWER SUPPLY MECHANISM IN THE HEATING ELEMENT CVD SYSTEM	ISHIBASHI, KEIJI
10662339	Not Issued	030	09/16/2003	FILM-FORMING SYSTEM AND FILM-FORMING METHOD	ISHIBASHI, KEIJI
10327132	Not Issued	160	12/24/2002	SILICON OXIDE FILM FORMATION METHOD	ISHIBASHI, KEIJI
10326092	Not Issued	030	12/23/2002	SILICON OXIDE FILM FORMATION METHOD	ISHIBASHI, KEIJI
10293698	Not Issued	030	11/14/2002	HEATING ELEMENT CVD SYSTEM AND HEATING ELEMENT CVD METHOD USING THE SAME	ISHIBASHI, KEIJI
10264264	6661152	150	10/04/2002	DIAMOND SUBSTRATE FOR SURFACE ACOUSTIC WAVE DEVICE, AND SURFACE ACOUSTIC WAVE DEVICE	ISHIBASHI, KEIJI
10130207	6593548	150	05/14/2002	HEATING ELEMENT CVD SYSTEM	ISHIBASHI, KEIJI
09633013	6375756	150	08/04/2000	METHOD FOR REMOVING A DEPOSITED FILM	ISHIBASHI, KEIJI
09633002	Not Issued	071	08/04/2000	HOT ELEMENT CVD APPARATUS AND A METHOD FOR REMOVING A DEPOSITED FILM	ISHIBASHI, KEIJI
09161946	6218392	150	09/29/1998	FUSED PYRIDAZINE COMPOUNDS	ISHIBASHI , KEIJI
09071446	6365009	150	05/01/1998	COMBINED RF-DC MAGNETRON SPUTTERING METHOD	ISHIBASHI , KEIJI
08784102	Not Issued	161	01/15/1997	ANTHRANILIC ACID DERIVATIVES	ISHIBASHI , KEIJI
08759301	Not Issued	163	12/02/1996	METHOD OF FABRICATING ITO TRANSPARENT CONDUCTIVE FILMS	ISHIBASHI , KEIJI
08619621	5849741	150	04/09/1996	FUSED PYRIDAZINE COMPOUNDS	ISHIBASHI , KEIJI
08531335	5606061	150	09/20/1995	THIOFORMAMIDE DERIVATIVES	ISHIBASHI , KEIJI

08531201	5605907	150	09/19/1995	CYCLOHEXANE DERIVATIVES	ISHIBASHI , KEIJI
08507476	5716993	150	09/14/1995	ANTHRANILIC ACID DERIVATIVES	ISHIBASHI , KEIJI
08347099	5607953	150	11/23/1994	BUTENOIC OR PROPENOIC ACID DERIVATIVE	ISHIBASHI , KEIJI
08300201	5478839	150	09/02/1994	CYCLOHEXANE DERIVATIVES	ISHIBASHI , KEIJI
08211701	5444066	150	04/26/1994	THIOFORMAMIDE DERIVATIVES HAVING HYPOTENSIVE ACTIVITY	ISHIBASHI , KEIJI
08169500	5430059	150	12/20/1993	BUTENOIC ACID DERIVATIVES	ISHIBASHI , KEIJI
07960883	5292770	150	10/14/1992	BUTENOIC ACID DERIVATIVES	ISHIBASHI , KEIJI
07959654	5382595	250	10/13/1992	BUTENOIC OR PROPENOIC ACID DERIVATIVE	ISHIBASHI , KEIJI
07837599	5166188	150	02/20/1992	BUTENOIC ACID DERIVATIVES	ISHIBASHI , KEIJI
07557713	5177089	150	07/25/1990	BUTENOIC OR PROPENOIC ACID DERIVATIVE	ISHIBASHI , KEIJI
07518508	Not Issued	166	05/03/1990	BUTENOIC ACID DERIVATIVES	ISHIBASHI , KEIJI
07354306	5047417	150	05/19/1989	BUTENOIC OR PROPENOIC ACID DERIVATIVES	ISHIBASHI , KEIJI

Inventor Search Completed: No Records to Display.

Search Another: Inventor

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<input type="text" value="ISHIBASHI"/>	<input type="text" value="KEIJI"/>	

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L Number	Hits	Search Text	DB	Time stamp
1	4	5149375.pn. or 5221427.pn. or 6107197.pn. or 6192897.pn.	USPAT; US-PGPUB	2004/02/20 10:14
2	1	6593548.pn.	USPAT; US-PGPUB	2004/02/20 10:16
3	3	(Ishibashi.in. or Anelva.as. or (Japan near2 Science).as.) and ((Pt or platinum) near3 (filament or coil or ((heat\$3 or hot) near2 element)))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/02/20 10:55
4	16	(Ishibashi.in. or Anelva.as. or (Japan near2 Science).as.) and ((Pt or platinum) with (clean\$3 or etch\$3))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/02/20 11:10
5	7	(Ishibashi.in. or Anelva.as. or (Japan near2 Science).as.) and ((Pt or platinum) with (filament or coil or ((heat\$3 or hot) near2 element)))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/02/20 11:10
6	4	((Ishibashi.in. or Anelva.as. or (Japan near2 Science).as.) and ((Pt or platinum) with (filament or coil or ((heat\$3 or hot) near2 element)))) not ((Ishibashi.in. or Anelva.as. or (Japan near2 Science).as.) and ((Pt or platinum) near3 (filament or coil or ((heat\$3 or hot) near2 element))))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/02/20 10:22
7	9	(Ishibashi.in. or Anelva.as. or (Japan near2 Science).as.) and (((clean\$3 or etch\$3 or fluorine or chlorine or fluorin\$5 or chlorin\$5 or halogen\$5 or halide) near2 gas) with (filament or coil or ((heat\$3 or hot) near2 element)))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/02/20 10:55
8	2228	(427/561,562,569,585,570,573).CCLS.	USPAT; US-PGPUB	2004/02/20 10:33
9	639	(427/235,237).CCLS.	USPAT; US-PGPUB	2004/02/20 10:33
10	2257	(427/248.1,255.23,255.28).CCLS.	USPAT; US-PGPUB	2004/02/20 10:33
11	421	(427/444).CCLS.	USPAT; US-PGPUB	2004/02/20 10:34
12	638	(118/722,70).CCLS.	USPAT; US-PGPUB	2004/02/20 10:34
13	1793	(134/1.1,1.2,1.3,19).CCLS.	USPAT; US-PGPUB	2004/02/20 10:34
14	421	(216/37,63).CCLS.	USPAT; US-PGPUB	2004/02/20 10:34
15	67	(118/723HC).CCLS.	USPAT; US-PGPUB	2004/02/20 10:34
16	7882	((427/561,562,569,585,570,573).CCLS.) ((427/235,237).CCLS.) ((427/248.1,255.23,255.28).CCLS.) ((427/444).CCLS.) ((118/722,70).CCLS.) ((134/1.1,1.2,1.3,19).CCLS.) ((216/37,63).CCLS.) ((118/723HC).CCLS.)	USPAT; US-PGPUB	2004/02/20 10:35
17	0	((118/723HC).CCLS.) and ((216/37,63).CCLS.)	USPAT; US-PGPUB	2004/02/20 10:35
18	39	((134/1.1,1.2,1.3,19).CCLS.) and (((216/37,63).CCLS.) or ((118/723HC).CCLS.))	USPAT; US-PGPUB	2004/02/20 11:15
19	1	6592771.pn. and (Pt or platinum)	USPAT; US-PGPUB	2004/02/20 10:41
20	5	((118/723HC).CCLS.) and (Pt or platinum)	USPAT; US-PGPUB	2004/02/20 10:42
21	46	((216/37,63).CCLS.) and (Pt or platinum)	USPAT; US-PGPUB	2004/02/20 10:42
22	46	((216/37,63).CCLS.) and (Pt or platinum)) not ((118/723HC).CCLS.) and (Pt or platinum))	USPAT; US-PGPUB	2004/02/20 10:42

23	12	((427/561,562,569,585,570,573).CCLS.) ((427/235,237).CCLS.) ((427/248.1,255.23,255.28).CCLS.) ((427/444).CCLS.) ((118/722,70).CCLS.) ((134/1.1,1.2,1.3,19).CCLS.) ((216/37,63).CCLS.) ((118/723HC).CCLS.)) and ((Pt or platinum) near5 (filament or coil or ((heat\$3 or hot) near2 element)))	USPAT; US-PGPUB	2004/02/20 10:46
24	14	((427/561,562,569,585,570,573).CCLS.) ((427/235,237).CCLS.) ((427/248.1,255.23,255.28).CCLS.) ((427/444).CCLS.) ((118/722,70).CCLS.) ((134/1.1,1.2,1.3,19).CCLS.) ((216/37,63).CCLS.) ((118/723HC).CCLS.)) and ((Pt or platinum) near8 (filament or coil or ((heat\$3 or hot) near2 element)))	USPAT; US-PGPUB	2004/02/20 10:46
25	2	((427/561,562,569,585,570,573).CCLS.) ((427/235,237).CCLS.) ((427/248.1,255.23,255.28).CCLS.) ((427/444).CCLS.) ((118/722,70).CCLS.) ((134/1.1,1.2,1.3,19).CCLS.) ((216/37,63).CCLS.) ((118/723HC).CCLS.)) and ((Pt or platinum) near8 (filament or coil or ((heat\$3 or hot) near2 element))) not (((427/561,562,569,585,570,573).CCLS.) ((427/235,237).CCLS.) ((427/248.1,255.23,255.28).CCLS.) ((427/444).CCLS.) ((118/722,70).CCLS.) ((134/1.1,1.2,1.3,19).CCLS.) ((216/37,63).CCLS.) ((118/723HC).CCLS.)) and ((Pt or platinum) near5 (filament or coil or ((heat\$3 or hot) near2 element))))	USPAT; US-PGPUB	2004/02/20 10:46
26	66	((427/561,562,569,585,570,573).CCLS.) ((427/235,237).CCLS.) ((427/248.1,255.23,255.28).CCLS.) ((427/444).CCLS.) ((118/722,70).CCLS.) ((134/1.1,1.2,1.3,19).CCLS.) ((216/37,63).CCLS.) ((118/723HC).CCLS.)) and ((Pt or platinum) with (clean\$3 or etch\$3))	USPAT; US-PGPUB	2004/02/20 10:47
27	63	((427/561,562,569,585,570,573).CCLS.) ((427/235,237).CCLS.) ((427/248.1,255.23,255.28).CCLS.) ((427/444).CCLS.) ((118/722,70).CCLS.) ((134/1.1,1.2,1.3,19).CCLS.) ((216/37,63).CCLS.) ((118/723HC).CCLS.)) and ((Pt or platinum) with (clean\$3 or etch\$3))) not (((427/561,562,569,585,570,573).CCLS.) ((427/235,237).CCLS.) ((427/248.1,255.23,255.28).CCLS.) ((427/444).CCLS.) ((118/722,70).CCLS.) ((134/1.1,1.2,1.3,19).CCLS.) ((216/37,63).CCLS.) ((118/723HC).CCLS.)) and ((Pt or platinum) near8 (filament or coil or ((heat\$3 or hot) near2 element))))	USPAT; US-PGPUB	2004/02/20 10:47
28	47	((427/561,562,569,585,570,573).CCLS.) ((427/235,237).CCLS.) ((427/248.1,255.23,255.28).CCLS.) ((427/444).CCLS.) ((118/722,70).CCLS.) ((134/1.1,1.2,1.3,19).CCLS.) ((216/37,63).CCLS.) ((118/723HC).CCLS.)) and (((clean\$3 or etch\$3 or fluorine or chlorine or fluorin\$5 or chlorin\$5 or halogen\$5 or halide) near2 gas) with (filament or coil or ((heat\$3 or hot) near2 element)))	USPAT; US-PGPUB	2004/02/20 10:51
29	3670	((Pt or platinum) with (filament or coil or ((heat\$3 or hot) near2 element)))	USPAT; US-PGPUB	2004/02/20 10:55

30	104	(((Pt or platinum) with (filament or coil or ((heat\$3 or hot) near2 element)))) same (((clean\$3 or etch\$3 or fluorine or chlorine or fluorin\$5 or chlorin\$5 or halogen\$5 or halide) near2 gas) or Cl2 or F2 or "Cl.sub.2" or "F.sub.2" or \$8fluoride or \$8chloride or NF3 or "NF.sub.3" or CF4 or "CF.sub.4" or C2F6 or "C.sub.2F.sub.6" or "C.sub.2 F.sub.6" or C3F8 or "C.sub.3 F.sub.8" or "C.sub.3F.sub.8" or CCl4 or "CCl.sub.4" or C2ClF5 or ClF3 or "ClF.sub.3" or CClF3 or "CClF.sub.3" or SF6 or "SF.sub.6")	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/02/20 11:02
31	90	(((Pt or platinum) with (filament or coil or ((heat\$3 or hot) near2 element)))) same (((clean\$3 or etch\$3) same (fluorine or chlorine or fluorin\$5 or chlorin\$5 or halogen\$5 or halide)) or Cl2 or F2 or "Cl.sub.2" or "F.sub.2" or \$8fluoride or \$8chloride or NF3 or "NF.sub.3" or CF4 or "CF.sub.4" or C2F6 or "C.sub.2F.sub.6" or "C.sub.2 F.sub.6" or C3F8 or "C.sub.3 F.sub.8" or "C.sub.3F.sub.8" or CCl4 or "CCl.sub.4" or C2ClF5 or ClF3 or "ClF.sub.3" or CClF3 or "CClF.sub.3" or SF6 or "SF.sub.6")	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/02/20 11:03
32	1	((((Pt or platinum) with (filament or coil or ((heat\$3 or hot) near2 element)))) same (((clean\$3 or etch\$3) same (fluorine or chlorine or fluorin\$5 or chlorin\$5 or halogen\$5 or halide)) or Cl2 or F2 or "Cl.sub.2" or "F.sub.2" or \$8fluoride or \$8chloride or NF3 or "NF.sub.3" or CF4 or "CF.sub.4" or C2F6 or "C.sub.2F.sub.6" or "C.sub.2 F.sub.6" or C3F8 or "C.sub.3 F.sub.8" or "C.sub.3F.sub.8" or CCl4 or "CCl.sub.4" or C2ClF5 or ClF3 or "ClF.sub.3" or CClF3 or "CClF.sub.3" or SF6 or "SF.sub.6")) not ((((Pt or platinum) with (filament or coil or ((heat\$3 or hot) near2 element)))) same (((clean\$3 or etch\$3 or fluorine or chlorine or fluorin\$5 or chlorin\$5 or halogen\$5 or halide) near2 gas) or Cl2 or F2 or "Cl.sub.2" or "F.sub.2" or \$8fluoride or \$8chloride or NF3 or "NF.sub.3" or CF4 or "CF.sub.4" or C2F6 or "C.sub.2F.sub.6" or "C.sub.2 F.sub.6" or C3F8 or "C.sub.3 F.sub.8" or "C.sub.3F.sub.8" or CCl4 or "CCl.sub.4" or C2ClF5 or ClF3 or "ClF.sub.3" or CClF3 or "CClF.sub.3" or SF6 or "SF.sub.6"))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/02/20 11:03

34	1	((((Pt or platinum) with (filament or coil or ((heat\$3 or hot) near2 element)))) same (clean\$3 or etch\$3) same (fluorine or chlorine or fluorin\$5 or chlorin\$5 or halogen\$5 or halide or Cl2 or F2 or "Cl.sub.2" or "F.sub.2" or \$8fluoride or \$8chloride or NF3 or "NF.sub.3" or CF4 or "CF.sub.4" or C2F6 or "C.sub.2F.sub.6" or "C.sub.2 F.sub.6" or C3F8 or "C.sub.3 F.sub.8" or "C.sub.3F.sub.8" or CCl4 or "CCl.sub.4" or C2ClF5 or ClF3 or "ClF.sub.3" or CClF3 or "CClF.sub.3" or SF6 or "SF.sub.6")) not (((Pt or platinum) with (filament or coil or ((heat\$3 or hot) near2 element)))) same (((clean\$3 or etch\$3 or fluorine or chlorine or fluorin\$5 or chlorin\$5 or halogen\$5 or halide) near2 gas) or Cl2 or F2 or "Cl.sub.2" or "F.sub.2" or \$8fluoride or \$8chloride or NF3 or "NF.sub.3" or CF4 or "CF.sub.4" or C2F6 or "C.sub.2F.sub.6" or "C.sub.2 F.sub.6" or C3F8 or "C.sub.3 F.sub.8" or "C.sub.3F.sub.8" or CCl4 or "CCl.sub.4" or C2ClF5 or ClF3 or "ClF.sub.3" or CClF3 or "CClF.sub.3" or SF6 or "SF.sub.6"))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/02/20 11:04
33	24	((((Pt or platinum) with (filament or coil or ((heat\$3 or hot) near2 element)))) same (clean\$3 or etch\$3) same (fluorine or chlorine or fluorin\$5 or chlorin\$5 or halogen\$5 or halide or Cl2 or F2 or "Cl.sub.2" or "F.sub.2" or \$8fluoride or \$8chloride or NF3 or "NF.sub.3" or CF4 or "CF.sub.4" or C2F6 or "C.sub.2F.sub.6" or "C.sub.2 F.sub.6" or C3F8 or "C.sub.3 F.sub.8" or "C.sub.3F.sub.8" or CCl4 or "CCl.sub.4" or C2ClF5 or ClF3 or "ClF.sub.3" or CClF3 or "CClF.sub.3" or SF6 or "SF.sub.6"))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/02/20 11:04
35	1035	(Pt or platinum) same ((clean\$3 or etch\$3) with (fluorine or chlorine or fluorin\$5 or chlorin\$5 or halogen\$5 or halide or Cl2 or F2 or "Cl.sub.2" or "F.sub.2" or \$8fluoride or \$8chloride or NF3 or "NF.sub.3" or CF4 or "CF.sub.4" or C2F6 or "C.sub.2F.sub.6" or "C.sub.2 F.sub.6" or C3F8 or "C.sub.3 F.sub.8" or "C.sub.3F.sub.8" or CCl4 or "CCl.sub.4" or C2ClF5 or ClF3 or "ClF.sub.3" or CClF3 or "CClF.sub.3" or SF6 or "SF.sub.6"))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/02/20 11:18
36	17	((Pt or platinum) same ((clean\$3 or etch\$3) with (fluorine or chlorine or fluorin\$5 or chlorin\$5 or halogen\$5 or halide or Cl2 or F2 or "Cl.sub.2" or "F.sub.2" or \$8fluoride or \$8chloride or NF3 or "NF.sub.3" or CF4 or "CF.sub.4" or C2F6 or "C.sub.2F.sub.6" or "C.sub.2 F.sub.6" or C3F8 or "C.sub.3 F.sub.8" or "C.sub.3F.sub.8" or CCl4 or "CCl.sub.4" or C2ClF5 or ClF3 or "ClF.sub.3" or CClF3 or "CClF.sub.3" or SF6 or "SF.sub.6")) and ((427/561,562,569,570,573).CCLS.) ((427/235,237).CCLS.) ((427/248.1,255.23,255.28).CCLS.) ((427/444).CCLS.) ((118/722,70).CCLS.) ((134/1.1,1.2,1.3,19).CCLS.) ((216/37,63).CCLS.) ((118/723HC).CCLS.))	USPAT; US-PGPUB	2004/02/20 11:05

37	1750	(coil or wire or filament or ((hot or heat\$4) near2 (element or cathode))) same ((clean\$3 or etch\$3) with (fluorine or chlorine or fluorin\$5 or chlorin\$5 or halogen\$5 or halide or Cl2 or F2 or "Cl.sub.2" or "F.sub.2" or \$8fluoride or \$8chloride or NF3 or "NF.sub.3" or CF4 or "CF.sub.4" or C2F6 or "C.sub.2F.sub.6" or "C.sub.2 F.sub.6" or C3F8 or "C.sub.3 F.sub.8" or "C.sub.3F.sub.8" or CCl4 or "CCl.sub.4" or C2ClF5 or ClF3 or "ClF.sub.3" or CClF3 or "CClF.sub.3" or SF6 or "SF.sub.6"))	USPAT; US-PGPUB	2004/02/20 11:09
38	72	((coil or wire or filament or ((hot or heat\$4) near2 (element or cathode))) same ((clean\$3 or etch\$3) with (fluorine or chlorine or fluorin\$5 or chlorin\$5 or halogen\$5 or halide or Cl2 or F2 or "Cl.sub.2" or "F.sub.2" or \$8fluoride or \$8chloride or NF3 or "NF.sub.3" or CF4 or "CF.sub.4" or C2F6 or "C.sub.2F.sub.6" or "C.sub.2 F.sub.6" or C3F8 or "C.sub.3 F.sub.8" or "C.sub.3F.sub.8" or CCl4 or "CCl.sub.4" or C2ClF5 or ClF3 or "ClF.sub.3" or CClF3 or "CClF.sub.3" or SF6 or "SF.sub.6")))) and ((427/561,562,569,585,570,573).CCLS.) ((427/235,237).CCLS.) ((427/248.1,255.23,255.28).CCLS.) ((427/444).CCLS.) ((118/722,70).CCLS.) ((134/1.1,1.2,1.3,19).CCLS.) ((216/37,63).CCLS.) ((118/723HC).CCLS.))	USPAT; US-PGPUB	2004/02/20 11:08
39	69	((coil or wire or filament or ((hot or heat\$4) near2 (element or cathode))) same ((clean\$3 or etch\$3) with (fluorine or chlorine or fluorin\$5 or chlorin\$5 or halogen\$5 or halide or Cl2 or F2 or "Cl.sub.2" or "F.sub.2" or \$8fluoride or \$8chloride or NF3 or "NF.sub.3" or CF4 or "CF.sub.4" or C2F6 or "C.sub.2F.sub.6" or "C.sub.2 F.sub.6" or C3F8 or "C.sub.3 F.sub.8" or "C.sub.3F.sub.8" or CCl4 or "CCl.sub.4" or C2ClF5 or ClF3 or "ClF.sub.3" or CClF3 or "CClF.sub.3" or SF6 or "SF.sub.6")))) and ((427/561,562,569,585,570,573).CCLS.) ((427/235,237).CCLS.) ((427/248.1,255.23,255.28).CCLS.) ((427/444).CCLS.) ((118/722,70).CCLS.) ((134/1.1,1.2,1.3,19).CCLS.) ((216/37,63).CCLS.) ((118/723HC).CCLS.)) not (((427/561,562,569,585,570,573).CCLS.) ((427/235,237).CCLS.) ((427/248.1,255.23,255.28).CCLS.) ((427/444).CCLS.) ((118/722,70).CCLS.) ((134/1.1,1.2,1.3,19).CCLS.) ((216/37,63).CCLS.) ((118/723HC).CCLS.)) and ((Pt or platinum) with (clean\$3 or etch\$3)))	USPAT; US-PGPUB	2004/02/20 11:08

40	450	((coil or wire or filament or ((hot or heat\$4) near2 (element or cathode))) same ((clean\$3 or etch\$3) with (fluorine or chlorine or fluorin\$5 or chlorin\$5 or halogen\$5 or halide or Cl2 or F2 or "Cl.sub.2" or "F.sub.2" or \$8fluoride or \$8chloride or NF3 or "NF.sub.3" or CF4 or "CF.sub.4" or C2F6 or "C.sub.2F.sub.6" or "C.sub.2 F.sub.6" or C3F8 or "C.sub.3 F.sub.8" or "C.sub.3F.sub.8" or CCl4 or "CCl.sub.4" or C2ClF5 or ClF3 or "ClF.sub.3" or CClF3 or "CClF.sub.3" or SF6 or "SF.sub.6")))) and (Pt or platinum)	USPAT; US-PGPUB	2004/02/20 11:09
41	293	((coil or wire or filament or ((hot or heat\$4) near2 (element or cathode))) same ((clean\$3 or etch\$3) with (fluorine or chlorine or fluorin\$5 or chlorin\$5 or halogen\$5 or halide or Cl2 or F2 or "Cl.sub.2" or "F.sub.2" or \$8fluoride or \$8chloride or NF3 or "NF.sub.3" or CF4 or "CF.sub.4" or C2F6 or "C.sub.2F.sub.6" or "C.sub.2 F.sub.6" or C3F8 or "C.sub.3 F.sub.8" or "C.sub.3F.sub.8" or CCl4 or "CCl.sub.4" or C2ClF5 or ClF3 or "ClF.sub.3" or CClF3 or "CClF.sub.3" or SF6 or "SF.sub.6")))) and (Pt or platinum)	USPAT; US-PGPUB	2004/02/20 11:09
42	96	((coil or wire or filament or ((hot or heat\$4) near2 (element or cathode))) same ((clean\$3 or etch\$3) with (fluorine or chlorine or fluorin\$5 or chlorin\$5 or halogen\$5 or halide or Cl2 or F2 or "Cl.sub.2" or "F.sub.2" or \$8fluoride or \$8chloride or NF3 or "NF.sub.3" or CF4 or "CF.sub.4" or C2F6 or "C.sub.2F.sub.6" or "C.sub.2 F.sub.6" or C3F8 or "C.sub.3 F.sub.8" or "C.sub.3F.sub.8" or CCl4 or "CCl.sub.4" or C2ClF5 or ClF3 or "ClF.sub.3" or CClF3 or "CClF.sub.3" or SF6 or "SF.sub.6")))) and ((Pt or platinum) with (filament or coil or wire or activat\$4 or decompos\$7 or ioniz\$6 or ((heat\$3 or hot) near2 (element or cathode))))	USPAT; US-PGPUB	2004/02/20 11:17
43	3339	(Pt or platinum) and ((clean\$3 or etch\$3) and (fluorine or chlorine or fluorin\$5 or chlorin\$5 or halogen\$5 or halide or Cl2 or F2 or "Cl.sub.2" or "F.sub.2" or \$8fluoride or \$8chloride or NF3 or "NF.sub.3" or CF4 or "CF.sub.4" or C2F6 or "C.sub.2F.sub.6" or "C.sub.2 F.sub.6" or C3F8 or "C.sub.3 F.sub.8" or "C.sub.3F.sub.8" or CCl4 or "CCl.sub.4" or C2ClF5 or ClF3 or "ClF.sub.3" or CClF3 or "CClF.sub.3" or SF6 or "SF.sub.6"))	EPO; JPO; DERWENT; IBM_TDB	2004/02/20 11:15
44	417	((Pt or platinum) and ((clean\$3 or etch\$3) and (fluorine or chlorine or fluorin\$5 or chlorin\$5 or halogen\$5 or halide or Cl2 or F2 or "Cl.sub.2" or "F.sub.2" or \$8fluoride or \$8chloride or NF3 or "NF.sub.3" or CF4 or "CF.sub.4" or C2F6 or "C.sub.2F.sub.6" or "C.sub.2 F.sub.6" or C3F8 or "C.sub.3 F.sub.8" or "C.sub.3F.sub.8" or CCl4 or "CCl.sub.4" or C2ClF5 or ClF3 or "ClF.sub.3" or CClF3 or "CClF.sub.3" or SF6 or "SF.sub.6")))) and ((filament or coil or wire or activat\$4 or decompos\$7 or ioniz\$6 or ((heat\$3 or hot) near2 (element or cathode))))	EPO; JPO; DERWENT; IBM_TDB	2004/02/20 11:15

45	52	((Pt or platinum) and ((clean\$3 or etch\$3) and (fluorine or chlorine or fluorin\$5 or chlorin\$5 or halogen\$5 or halide or Cl2 or F2 or "Cl.sub.2" or "F.sub.2" or \$8fluoride or \$8chloride or NF3 or "NF.sub.3" or CF4 or "CF.sub.4" or C2F6 or "C.sub.2F.sub.6" or "C.sub.2 F.sub.6" or C3F8 or "C.sub.3 F.sub.8" or "C.sub.3F.sub.8" or CCl4 or "CCl.sub.4" or C2ClF5 or ClF3 or "ClF.sub.3" or CClF3 or "CClF.sub.3" or SF6 or "SF.sub.6")))) and ((Pt or platinum) with (filament or coil or wire or activat\$4 or decompos\$7 or ioniz\$6 or ((heat\$3 or hot) near2 (element or cathode))))))	EPO; JPO; DERWENT; IBM_TDB	2004/02/20 11:16
46	9433	((Pt or platinum) with (filament or coil or wire or activat\$4 or decompos\$7 or ioniz\$6 or ((heat\$3 or hot) near2 (element or cathode))))	EPO; JPO; DERWENT; IBM_TDB	2004/02/20 11:17
47	25	((((Pt or platinum) with (filament or coil or wire or activat\$4 or decompos\$7 or ioniz\$6 or ((heat\$3 or hot) near2 (element or cathode)))))) and ((clean\$3 or etch\$3) with (fluorine or chlorine or fluorin\$5 or chlorin\$5 or halogen\$5 or halide or Cl2 or F2 or "Cl.sub.2" or "F.sub.2" or \$8fluoride or \$8chloride or NF3 or "NF.sub.3" or CF4 or "CF.sub.4" or C2F6 or "C.sub.2F.sub.6" or "C.sub.2 F.sub.6" or C3F8 or "C.sub.3 F.sub.8" or "C.sub.3F.sub.8" or CCl4 or "CCl.sub.4" or C2ClF5 or ClF3 or "ClF.sub.3" or CClF3 or "CClF.sub.3" or SF6 or "SF.sub.6"))))	EPO; JPO; DERWENT; IBM_TDB	2004/02/20 11:19
48	51	((((Pt or platinum) with (filament or coil or wire or activat\$4 or decompos\$7 or ioniz\$6 or ((heat\$3 or hot) near2 (element or cathode)))))) and ((clean\$3 or etch\$3) near2 gas))	EPO; JPO; DERWENT; IBM_TDB	2004/02/20 11:19
49	45	((((Pt or platinum) with (filament or coil or wire or activat\$4 or decompos\$7 or ioniz\$6 or ((heat\$3 or hot) near2 (element or cathode)))))) and ((clean\$3 or etch\$3) near2 gas)) not (((Pt or platinum) with (filament or coil or wire or activat\$4 or decompos\$7 or ioniz\$6 or ((heat\$3 or hot) near2 (element or cathode)))))) and ((clean\$3 or etch\$3) with (fluorine or chlorine or fluorin\$5 or chlorin\$5 or halogen\$5 or halide or Cl2 or F2 or "Cl.sub.2" or "F.sub.2" or \$8fluoride or \$8chloride or NF3 or "NF.sub.3" or CF4 or "CF.sub.4" or C2F6 or "C.sub.2F.sub.6" or "C.sub.2 F.sub.6" or C3F8 or "C.sub.3 F.sub.8" or "C.sub.3F.sub.8" or CCl4 or "CCl.sub.4" or C2ClF5 or ClF3 or "ClF.sub.3" or CClF3 or "CClF.sub.3" or SF6 or "SF.sub.6"))))	EPO; JPO; DERWENT; IBM_TDB	2004/02/20 11:19